

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Choi et al. PATENT APPLICATION  
Serial No: Unassigned Group Art Unit: Unassigned  
Filed: Herewith Examiner: Unassigned  
For: A METHOD OF MANUFACTURING A VACUUM CHUCK USED IN  
IMPRINT LITHOGRAPHY

PRELIMINARY AMENDMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Before calculation of the fees due, please  
preliminarily amend the application as follows:

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IN THE TITLE:

Please cancel "HIGH PRECISION ORIENTATION ALIGNMENT AND GAP CONTROL STAGES FOR IMPRINT LITHOGRAPHY PROCESSES" and replace with "A METHOD OF MANUFACTURING A VACUUM CHUCK USED IN IMPRINT LITHOGRAPHY".

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IN THE DRAWINGS:

Applicant proposes to amend Figs. 4, 6B, and 11B of the patent application to harmonize with the description of the invention in the written Specification. To that end, a separate letter to the Chief Draftsperson is attached requesting that the Drawings be corrected.

Fig. 4 has been amended to include elements 110 and 114 as indicated on the accompanying drawings.

Fig. 6B has been amended to include elements 210 and to show frame 130 and re-label the same as element 206 as indicated on the accompanying drawings.

Fig. 11B has been amended to show wall shape 462 and re-label the same as element 464 and to show smooth curved cross section 462 and re-label the same as element 466 as indicated on the accompanying drawings.

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